Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	123535	(field$4 NEAR3 effect$4 NEAR3 transistor$4) OR FET OR MOS$1FET	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:34
L2	854	L1 AND etch$4 AND (((hydrogen$4 ADJ bromide$4) OR HBr) WITH (chlori$4 OR Cl2 OR "Cl.sub.2"))	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:34
L3	516	L2 AND side$1wall$4	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:31
L4	483	L3 AND poly$1silicon	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:32
L6	112	L4 AND (optical$4 OR scatteromet$4)	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:33
L7	12762	((438/5,9,14,16,714,719,720,721, 723,724,740,743,744) or (216/60, 67,79) or (430/5)).CCLS.	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:33
L9	22	L6 AND L7	US-PGPUB; USPAT	OR	OFF	2005/11/09 11:34
L10	106004	(field$4 NEAR3 effect$4 NEAR3 transistor$4) OR FET OR MOS$1FET	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/09 11:34
L11	12	L10 AND etch$4 AND (((hydrogen$4 ADJ bromide$4) OR HBr) WITH (chlori$4 OR Cl2 OR "Cl.sub.2"))	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/09 11:34